



Legislation Details (With Text)

**File #:** Res 1631-2008      **Version:** \*      **Name:** LU 839 - Landmark, Whitney Museum/High Line, Manhattan (C080408PPM)  
**Type:** Resolution      **Status:** Adopted  
**In control:** Committee on Land Use

**On agenda:** 9/24/2008

**Enactment date:**      **Enactment #:**

**Title:** Resolution approving the decision of the City Planning Commission on ULURP No. C 080408 PPM, for the disposition of city-owned property located at Block 644, Lots 1 and 10, which includes the disposition of easements over portions of Block 644 Lots 1 and 10, Borough of Manhattan (L.U. No. 839).

**Sponsors:** Melinda R. Katz, Jessica S. Lappin

**Indexes:**

**Attachments:** 1. Committee Report, 2. Hearing Transcript - Stated Meeting 9/24/08

Date	Ver.	Action By	Action	Result
9/17/2008	*	Committee on Land Use	Approved by Committee	
9/24/2008	*	City Council	Approved, by Council	Pass

THE COUNCIL OF THE CITY OF NEW YORK  
RESOLUTION NO. 1631

Resolution approving the decision of the City Planning Commission on ULURP No. C 080408 PPM, for the disposition of city-owned property located at Block 644, Lots 1 and 10, which includes the disposition of easements over portions of Block 644 Lots 1 and 10, Borough of Manhattan (L.U. No. 839).

By Council Members Katz and Lappin

WHEREAS, the City Planning Commission filed with the Council on August 18, 2008 its decision dated August 11, 2008 (the "Decision") on the application submitted pursuant to Section 197-c of the New York City Charter by the Department of Citywide Administrative Services and the Department of Small Business Services, for the disposition to the New York City Economic Development Corporation of city-owned property, pursuant to zoning, located at Block 644 Lots 1 and 10, which includes the disposition of easements over portions of Block 644 Lots 1 and 10 is approved, with the following restriction: The disposition is restricted to a building containing a museum use and a maintenance and operations facility (High Line Support Facility) for the High Line pursuant to Application Numbers C 080409 ZSM and C 080407 PCM), Community District 2, Borough of Manhattan (ULURP No. C 080408 PPM) (the "Application");

WHEREAS, the Application is related to Applications Numbers N 080406 ZRM (L.U. No. 837) Zoning Text Amendment to Section 74-92, to permit height and setback modifications for a building containing a Use Group 3A museum use in a M1-5 zoning district on a zoning lot over which the High Line passes; C 080407 PCM (L.U. No. 838), site selection and acquisition for a facility to be used by the Parks Department in connection with the operation and maintenance of the High Line public open space; C 080409 ZSM (L.U. No. 840), special permit pursuant to the proposed amended Section 74-921(a) to modify use to allow a museum in a M1-5 zoning district; and the proposed Section 74-921(b) to modify bulk in a building containing a museum

use in a M1-5 district, located on a zoning lot over which the High Line passes

WHEREAS, the Decision is subject to review and action by the Council pursuant to Section 197-d(b)(3) of the City Charter;

WHEREAS, upon due notice, the Council held a public hearing on the Decision and Application on September 16, 2008;

WHEREAS, the Council has considered the relevant environmental issues and the Negative Declaration, issued on April 30, 2008 (CEQR No. 07SBS021M); and

WHEREAS, the Council has considered the land use implications and other policy issues relating to the Decision and Application;

RESOLVED:

The Council finds that the action described herein will have no significant effect on the environment.

Pursuant to Section 197-d of the City Charter and on the basis of the Application and the Decision, the Council approves the Decision.

Adopted.

Office of the City Clerk, }  
The City of New York, } ss.:

I hereby certify that the foregoing is a true copy of a Resolution passed by The Council of The City of New York on September 24, 2008, on file in this office.

.....  
City Clerk, Clerk of The Council